



## 基于MEMS微触觉测头和纳米测量机的特征尺寸测量\*

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摘 要：

针对微小结构几何量测量的需求，通过集成MEMS微触觉测头和纳米测量机构建了高精度的测量系统。在验证测头性能的基础上，完成了一系列判断测头测量力和精度的实验，在轴向、同向横向、异向横向三个方向测量的标准偏差分别为41.7552nm, 6.05μm, 6.16μm，同时，在扫描实验中进程回程扫描差值的标准偏23.088nm。

关键词：微机电系统，微触觉测头，尺寸测量，纳米测量机

### Dimension measurement based on MEMS micro tactile probe and nanomeasuring machine

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**Abstract:**

According to dimension measurement requirement of micro structure, a measurement system combined by MEMS micro tactile probe and nanomeasuring machine is constructed. On basis of performance verification of probe's output, a series of tests are done. The standard deviations of measurement in same vertical, same transverse direction, and opposite transverse direction are 41.7552nm, 6.05μm, 6.16μm separately. The standard deviation of difference between trace and retrace in scanning test is 23.088nm.

**Keywords:** MEMS, Micro tactile probe, Dimension measurement, Nanomeasuring machine

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